



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

July 30, 2026

IGI Report Number

DESCRIPTION

SHAPE AND CUTTING STYLE

MEASUREMENTS

GRADING RESULTS

CARAT WEIGHT

COLOR GRADE

CLARITY GRADE

CUT GRADE

ADDITIONAL GRADING INFORMATION

POLISH

SYMMETRY

FLUORESCENCE

INSCRIPTION(S)

COMMENTS: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG822617161

Report verification at [igi.org](#)

PROPORTIONS

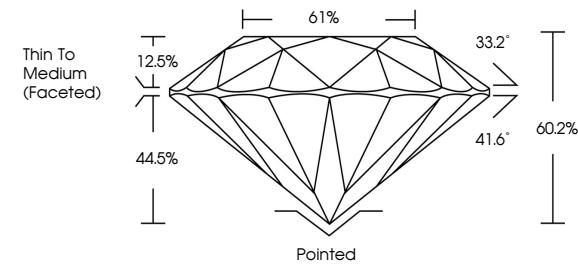


Diagram showing proportions: 61%, 33.2°, 41.6°, 44.5%, 12.5%, 60.2%, Thin To Medium (Faceted), Pointed

CLARITY CHARACTERISTICS

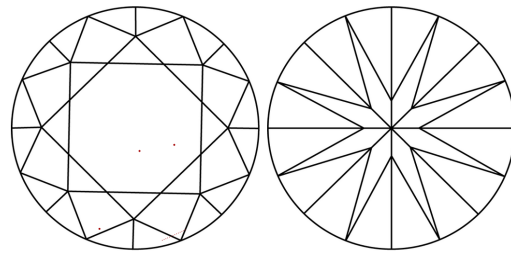
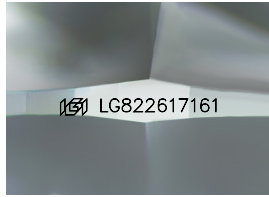


Diagram showing clarity characteristics with red and green symbols.

KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.



Sample Image Used

COLOR

D	E	F	G	H	I	J	Faint	Very Light	Light
---	---	---	---	---	---	---	-------	------------	-------

CLARITY

FL	IF	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	I ¹⁻³
Flawless	Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included

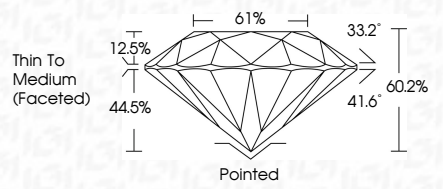


Diagram showing proportions: 61%, 33.2°, 41.6°, 44.5%, 12.5%, 60.2%, Thin To Medium (Faceted), Pointed

ADDITIONAL GRADING INFORMATION

POLISH

SYMMETRY

FLUORESCENCE

INSCRIPTION(S)

COMMENTS: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



IGI

July 30, 2026

IGI Report No LG822617161

ROUND BRILLIANT

7.45 - 7.49 X 4.50 MM

1.52 CARAT

E

VVS 2

EXCELLENT

60.2%

61%

Thin To Medium (Faceted)

Pointed

EXCELLENT

EXCELLENT

NONE

IGI LG822617161

Comments: The Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa



© IGI 2020, International Gemological Institute

FD - 10 20



THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES.